

# Large-Signal Modeling and Characterization of High-Current Effects in InGaP/GaAs HBTs

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**Abstract**—High-current effects in InGaP/GaAs heterojunction bipolar transistors (HBTs) were modeled and characterized. In addition to the self-heating effect, high currents were found to degrade large-signal performance mainly through Kirk and quasi-saturation effects. New formalisms in terms of base transit time and base–collector diffusion capacitance were used to modify the conventional Gummel–Poon model. This new model was verified against large-signal characteristics measured at 2 GHz. The validity of the new model for HBTs of different emitter geometry was also explored.

**Index Terms**—Charge carrier injection, charge carrier lifetime, charge carrier processes, heterojunction bipolar transistors, microwave devices, microwave power amplifiers, semiconductor heterojunction.

## NOMENCLATURE AND TYPICAL VALUES

### A. Physical Device Parameters

$\epsilon$	$= 1.16 \times 10^{-12}$ F/cm. Dielectric constant of GaAs.
$N_B$	$= 4 \times 10^{19}$ cm $^{-3}$ . Base doping.
$x$ ( $\mu\text{m}$ )	Depth from the metallurgical base.
$W_B$	$= 0.08 \mu\text{m}$ . Base thickness.
$\Delta W_B$ ( $\mu\text{m}$ )	$= (6)$ . Extent of base push out.
$\phi_{CB}$	$= \phi_{CB0} + \delta\phi_{CB}(T_J - 298)$ . Collector–base built-in potential.
$\phi_{CB0}$	$= 1.31$ V. $\phi_{CB}$ at $T_J = 298$ K.
$\delta\phi_{CB}$	$= -1.68 \times 10^{-3}$ V/K. Temperature coefficient of $\phi_{CB}$ .
$N_C$	$= 2 \times 10^{16}$ cm $^{-3}$ . Collector doping.
$W_C$	$= 0.5 \mu\text{m}$ . Collector thickness.
$X_C$	$= 0.5$ . Area ratio of emitter mesa versus base mesa.
$A_E$	$= 300 \mu\text{m}^2$ . Total emitter area.
$I_B$ (A)	Base current.
$J_B$	$= I_B/A_E$ . Base current density.

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$I_E$ (A)	Emitter current.
$J_E$	$= I_E/A_E$ . Emitter current density.
$I_C$ (A)	Collector current.
$J_C$	$= I_C/A_E$ . Collector current density.
$J_K$	$= (3)$ . Threshold $J_C$ for Kirk effect.
$J_Q$	$= (4)$ . Threshold $J_C$ for quasi-saturation.
$V_{BE}$ (V)	Base–emitter voltage.
$V_{BC}$ (V)	Base–collector voltage.
$V_{BCI}$	$= V_{BC} + I_C R_C$ . Intrinsic base–collector voltage.
$V_{CE}$ (V)	Collector–emitter voltage.
$E$ (V/cm)	Electric field.
PAE	Power-added efficiency.
$T_C$ ( $^{\circ}$ C)	Chuck temperature.
$T_J$ (K)	$= 273 + T_C + \Theta I_C V_{CE} \{1 - \exp(-t/\tau_T)\}$ . Junction temperature.
$\Theta$	$= \Theta_0 + \delta\Theta(T_C - 25)$ . Thermal resistance.
$\Theta_0$	$= 280$ $^{\circ}$ C/W. $\Theta$ at $T_C = 25$ $^{\circ}$ C.
$\delta\Theta$	$= 0.57$ /W. Temperature coefficient of $\Theta$ .
$t$ ( $\mu\text{s}$ )	Time.
$\tau_T$	$= 8.6 \mu\text{s}$ . Temperature rise time.
$V_T$	$= kT_J/q$ . Thermal voltage.
$k$	$= 8.62 \times 10^{-5}$ eV/K. Boltzmann constant.
$q$	$= 1.60 \times 10^{-19}$ C. Elementary charge.
$V_{TO}$	$= 26$ mV. $V_T$ at $T_J = 298$ K.
$p$ (cm $^{-3}$ )	Hole concentration.
$n$ (cm $^{-3}$ )	Electron concentration.
$n_C$	$= (7)$ . $n$ at the junction between the extended base and remaining collector.
$n_0$	$= N_{SC} N_{SV} / N_C = 1.7 \times 10^{20}$ cm $^{-3}$ . $n_C - J_C / v_{SAT}$ with $V_{BCI} = E_G$ .
$N_{SC}$	$= 4.7 \times 10^{17}$ cm $^{-3}$ . Density of states in conduction band.
$N_{SV}$	$= 7.8 \times 10^{18}$ cm $^{-3}$ . Density of states in valence band.
$E_G$	$= 1.4$ eV. Energy gap of GaAs.
$D_P$	$= 6.5 \text{ cm}^2/\text{s}$ . Hole diffusivity in extended base.
$D_N$	$= 78 \text{ cm}^2/\text{s}$ . Electron diffusivity in extended base.
$\mu_P$	$= 250 \text{ cm}^2/\text{Vs}$ . Hole mobility in extended base.
$\mu_N$	$= 3 \times 10^3 \text{ cm}^2/\text{Vs}$ . Electron mobility in extended base.
$v_{SAT}$	$= v_{SAT0} + \delta v_{SAT}(T_J - 298)$ . Electron saturated velocity.
$v_{SAT0}$	$= 8.33 \times 10^6 \text{ cm/s}$ . $v_{SAT}$ at $T_J = 298$ K.

$\delta v_{SAT}$	$= -1.5 \times 10^{-3}$ cm/s K. Temperature coefficient of $v_{SAT}$ .	$N_F$	$= N_{FO} + \delta N_F(T_J - 298)$ . Forward collector ideality factor.
$f$ (GHz)	Frequency.	$N_{FO}$	$= 1.04 \cdot N_F$ at $T_J = 298$ K.
$\omega$	$= 2\pi f$ . Angular frequency.	$\delta N_F$	$= -6.5 \times 10^{-5}$ /K. Temperature coefficient of $N_F$ .
<i>B. Small-Signal Model Parameters</i> ( $V_{CE} = 1.6$ V, $J_C = 9.3 \times 10^4$ A/cm <sup>2</sup> , $T_C = 25^\circ$ C)			
$G_{BE}$	$= 7.72$ S. Emitter conductance.	$\beta_F$	$= \beta_{FO} / \{1 + ( T_J - T_{BF0} /T_{BF})^{MBF}\}$ . Forward current gain.
$C_{BEJ}$	$= 2.4$ pF. Base-emitter depletion capacitance.	$\beta_{FO}$	$= 250$ . Peak value of $\beta_F$ .
$C_{BED}$	$= 55.8$ pF. Base-emitter diffusion capacitance.	$T_{BF0}$	$= 370$ K. Temperature at which $\beta_F$ peaks.
$C_{CET}$	$= C_{BED}$ . Collector-emitter transcapacitance.	$T_{BF}$	$= 150$ K. $\beta_F$ rolloff temperature.
$G_{BC}$	$= 3.3 \times 10^{-5}$ S. Intrinsic collector conductance.	$MBF$	$= 4$ . $\beta_F$ rolloff factor.
$C_{BC}$	$= C_{BCJ} + C_{BCD} = 0.9$ pF. Intrinsic collector capacitance.	$I_{BER}$	$=$
$G_{EX}$	$= 6.0 \times 10^{-4}$ S. Extrinsic collector conductance.	$I_{SFR0}$	$I_{SFR0} \exp(V_{AFR}/V_T) \{ \exp(V_{BE}/N_{FR}V_T) - 1 \}$ . Forward base-emitter current.
$C_{EX}$	$= 0.3$ pF. Extrinsic-collector capacitance.	$V_{AFR}$	$= 42.9$ A. Forward base saturation current.
$\alpha_F$	$= \alpha_0 \exp(-j\omega\tau_C) / \{1 + j\omega(\tau_B + r_E C_{BEJ})\}$ . Common-base forward current gain.	$N_{FR}$	$= 1.16$ V. Forward base activation potential.
$\alpha_0$	$= 0.991$ . DC value of $\alpha$ .	$N_{FR0}$	$= N_{FR0} + \delta N_{FR}(T_J - 298)$ . Forward base ideality factor.
$\tau_B$	$= 7.3$ ps. Base transit time.	$\delta N_{FR}$	$= 1.52 \cdot N_{FR}$ at $T_J = 298$ K.
$\tau_C$	$= 0.6$ ps. Collector transit time.	$I_{BR}$	$= 3.5 \times 10^{-4}$ /K. Temperature coefficient of $N_{FR}$ .
$r_E$	$= V_T/N_F I_E$ . Dynamic emitter resistance.	$I_{ER}$	$= (I_{ER}/\beta_R) + I_{BCI}$ . Base current in reverse operation.
$R_{BI}$	$= 1.0 \Omega$ . Intrinsic base resistance.	$I_{SR0}$	$= I_{SR0} \exp(V_{AR}/V_T) \{ \exp(V_{BC}/N_R V_T) - 1 \}$ . Emitter current in reverse operation.
$R_B$	$= 0.74 \Omega$ . Extrinsic base resistance.	$V_{AR}$	$= 5.66 \times 10^5$ A. Reverse emitter saturation current.
$R_E$	$= 0.75 \Omega$ . Extrinsic emitter resistance.	$N_{R0}$	$= 1.69$ V. Reverse emitter activation potential.
$R_C$	$= 2.3 \Omega$ . Extrinsic collector resistance.	$\delta N_R$	$= 1.12$ . Reverse emitter ideality factor at 298 K.
$L_B$	$= 40$ pH. Base inductance.	$\beta_R$	$= -1.1 \times 10^{-4}$ /K. Temperature coefficient of $N_R$ .
$L_E$	$= 26$ pH. Emitter inductance.	$\beta_{R0}$	$= \beta_{R0} + \delta \beta_R(T_J - 298)$ . Reverse current gain.
$L_C$	$= 42$ pH. Collector inductance.	$\delta \beta_R$	$= 0.55 \cdot \beta_R$ at $T_J = 298$ K.
<i>C. Large-Signal Model Parameters</i>			
$\tau_{B0}$	$= 1.8$ ps. Small current base transit time.	$I_{BCI}$	$= -7.0 \times 10^{-4}$ /K. Temperature coefficient of $\beta_R$ .
$\tau_{BK}$	$= 12$ ps. Characteristic increase in $\tau_B$ due to Kirk effect.	$I_{SRR0}$	$=$
$J'_K$	$= (11)$ . Semiempirical expression for $J_K$ .	$V_{ARR}$	$X_C I_{SRR0} \exp(V_{ARR}/V_T) \{ \exp(V_{BC}/N_{RR} V_T) - 1 \}$ . Reverse base-collector current.
$J'_{K0}$	$= 4.0 \times 10^4$ A/cm <sup>2</sup> . $J'_K$ at $T_J = 298$ K.	$N_{RR}$	$= 12.0$ A. Reverse base saturation current.
$J_0$	$= 6.6 \times 10^4$ A/cm <sup>2</sup> . $\tau_B = \tau_{B0} + \tau_{BK}$ when $J_C = J_K + J_0$ .	$I_{EX}$	$= 0.864$ V. Reverse base activation potential.
$V_{PT}$	$= 2.2$ V. Collector-base punch-through voltage.	$R_B$	$= N_{RR0} + \delta N_{RR}(T_J - 298)$ . Reverse base ideality factor.
$M_K$	$= 3.0$ . Fitting parameter for $J_K$ dependence on $V_{BCI}$ .	$R_{B0}$	$= 1.94 \cdot N_{RR}$ at $T_J = 298$ K.
$\tau_{BQ}$	$= 0.4 \mu$ s. Fitting factor for quasi-saturation.	$\delta R_B$	$= -1.1 \times 10^{-4}$ /K. Temperature coefficient of $N_{RR}$ .
$\tau_C$	$= \tau_{C0}(1 + \tau_{CI} J_C - \tau_{CV} V_{BCI})$ . Collector transit time.	$R_E$	$= I_{BCI}(1 - X_C)/X_C$ . Extrinsic reverse base-collector current.
$\tau_{C0}$	$= 1.0$ ps. Low-power value of $\tau_C$ .	$R_{E0}$	$= R_{B0} + \delta R_B(T_J - 298)$ . Base resistance.
$\tau_{CI}$	$= 2.0 \times 10^{-5}$ cm <sup>2</sup> /A. Current coefficient of $\tau_C$ .	$\delta R_E$	$= 0.45 \Omega$ . $R_B$ at $T_J = 298$ K.
$\tau_{CV}$	$= 0.36$ /V. Voltage coefficient of $\tau_C$ .	$R_C$	$= 2.3 \text{ m}\Omega/\text{K}$ . Temperature coefficient of $R_B$ .
$I_{BF}$	$= (I_{CF}/\beta_F) + I_{BER}$ . Base current in forward operation.	$R_{C0}$	$= R_{E0} + \delta R_E(T_J - 298)$ . Emitter resistance.
$I_{CF}$	$= I_{SF0} \exp(V_{AF}/V_T) \{ \exp(V_{BE}/N_F V_T) - 1 \}$ . Collector current in forward operation.	$\delta R_C$	$= 0.9 \Omega$ . $R_E$ at $T_J = 298$ K.
$I_{SF0}$	$= 5.91 \times 10^3$ A. Forward collector saturation current.	$C_{BEJ}$	$= -1.2 \text{ m}\Omega/\text{K}$ . Temperature coefficient of $R_E$ .
$V_{AF}$	$= 1.62$ V. Forward collector activation potential.		$= R_{C0} + \delta R_C(T_J - 298)$ . Collector resistance.
			$= 1.4 \Omega$ . $R_C$ at $T_J = 298$ K.
			$= 7.3 \text{ m}\Omega/\text{K}$ . Temperature coefficient of $R_C$ .
			$= C_{JE}(1 - V_{BE}/\phi_{EB})^{-MJE}$ . Base-emitter junction capacitance.

$C_{JE}$	$= C_{JE0} + \delta C_{JE}(T_J - 298)$ . Zero-bias base-emitter capacitance.
$C_{JE0}$	$= 1.1 \text{ pF}$ . $C_{JE}$ at $T_J = 298 \text{ K}$ .
$\delta C_{JE}$	$= 6.87 \times 10^{-4} \text{ pF/K}$ . Temperature coefficient of $C_{JE}$ .
$\phi_{EB}$	$= \phi_{EB0} + \delta \phi_{EB}(T_J - 298)$ . Emitter-base built-in potential.
$\phi_{EB0}$	$= 2.21 \text{ V}$ . $\phi_{EB}$ at $T_J = 298 \text{ K}$ .
$\delta \phi_{EB}$	$= -1.14 \times 10^{-3} \text{ V/K}$ . Temperature coefficient of $\phi_{EB}$ .
$MJE$	$= 0.45$ . Emitter grading factor.
$Q_{BEJ}$	$= \int C_{BEJ} dV_{BE}$ . Base-emitter junction charge.
$C_{BED}$ (pF)	Base-emitter diffusion capacitance.
$Q_{BED}$	$= \int C_{BED} dV_{BE}$ . Base-emitter diffusion charge.
$C_{BCJ}$	$= X_C \{C_{JC}(1 - V_{BC}/\phi_{BIC})^{-MJC} + C_{BCPT}\}$ . Intrinsic base-collector junction capacitance.
$C_{JC}$	$= C_{JC0} + \delta C_{JC}(T_J - 298)$ . Zero-bias collector capacitance.
$C_{JC0}$	$= 0.85 \text{ pF}$ . $C_{JC}$ at $T_J = 298 \text{ K}$ .
$\delta C_{JC}$	$= 1.48 \times 10^{-3} \text{ pF/K}$ . Temperature coefficient of $C_{JC}$ .
$MJC$	$= 0.5$ . Collector grading factor.
$C_{BCPT}$	$= 0.12 \text{ pF}$ . Collector punch-through capacitance.
$Q_{BCJ}$	$= \int C_{BCJ} dV_{BCI}$ . Base-collector junction charge.
$C_{EX}$	$= C_{BCJ}(1 - X_C)/X_C$ . Extrinsic collector junction capacitance.
$Q_{EX}$	$= \int C_{EX} dV_{BCI}$ . Base-collector junction charge.
$C_{BCD}$	$= (9)$ . Base-collector diffusion capacitance.
$Q_{BCD}$	$= \int C_{BCD} dV_{BCI}$ . Base-collector diffusion charge.

## I. INTRODUCTION

AS THE trend toward lower supply voltage continues, current-induced phenomena such as the Kirk and quasi-saturation effects [1] become increasingly important for power heterojunction bipolar transistors (HBTs). For example, Fig. 1 shows that, although the HBT is typically biased with a quiescent  $J_C$  of the order of  $10^4 \text{ A/cm}^2$ , under a large RF input signal, the instantaneous current can reach  $10^5 \text{ A/cm}^2$ .

The high-current effects are often mixed with high-temperature effects because, even at 1 V, a current density of  $10^5 \text{ A/cm}^2$  can eventually increase the junction temperature by the order of  $100 \text{ }^\circ\text{C}$ . Thus, although high-temperature effects of HBTs have been investigated extensively [2]–[11], high-current effects of HBTs have seldom been studied separately. The Kirk effect is often modeled empirically [8], [9] while the quasi-saturation effect is simply ignored. This paper attempts to analyze the high-current and high-temperature effects separately before their joint manifestation.

Through this analysis, it was found that, if the self-heating effect is under control (i.e., the HBT is thermally stable) and

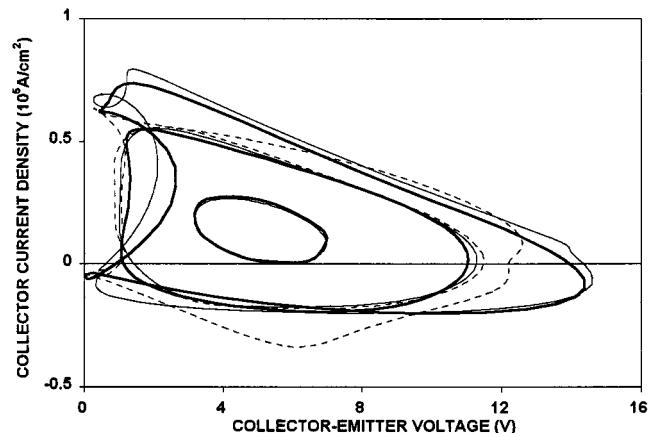


Fig. 1. (—) Measured dynamic load lines of a  $4 \times 75 \mu\text{m}^2$  HBT at 2 GHz versus that (—) modeled with both high-current and high-temperature effects and (—) modeled with just the high-temperature effect. Under quiescent conditions,  $V_{CE} = 5 \text{ V}$  and  $J_B = 1.2 \times 10^2 \text{ A/cm}^2$ . Input and output matched for maximum PAE.  $P_{IN} = -5, 5$ , and  $15 \text{ dBm}$ .  $T_C = 25 \text{ }^\circ\text{C}$ .

the operating frequency is much less than the cutoff frequency, the Kirk effect can be relatively benign. Thus, there exists wide latitude, over which significant performance improvement can be achieved by driving the HBT beyond the onset of the Kirk effect, but before the onset of the quasi-saturation effect. Therefore, the most salient feature of the present large-signal model is a newly developed forward diffusion charge model. This new charge model can account for the variation of base transit time and collector diffusion capacitance over a very wide current range. The present large-signal model eliminates the deficiencies of the standard Gummel-Poon model and accurately predicts the HBT performance under deep gain compression, as will be shown in Sections II–IV.

## II. EXPERIMENTAL

This analysis is based on InGaP/GaAs HBT devices with one emitter finger surrounded by two base fingers and one collector finger on one side. Except in Section IV-D, the emitter finger is  $4\text{-}\mu\text{m}$  wide and  $75\text{-}\mu\text{m}$  long. After the HBTs are fabricated on a GaAs wafer, it is thinned to  $100 \mu\text{m}$  before eutectic mounting on a copper carrier. On-wafer ground is provided by through-substrate via holes. For deembedding of parasitic pad capacitances and line delays, transmission-line test structures were fabricated together with the HBTs on the same wafer.

The HBTs were characterized under dc and RF, small- and large-signal, and CW and pulsed conditions, with  $J_C = 0$  to  $3 \times 10^5 \text{ A/cm}^2$ ,  $f = 2$  to  $30 \text{ GHz}$ , and  $T_C = 5$  to  $145 \text{ }^\circ\text{C}$ .  $\Theta$  and  $T_J$  are extracted from the measured collector characteristics in a conventional manner [12] then reoptimized to fit all Gummel plots. A voltage supply is used to bias the base through a  $33\text{-}\Omega$  series resistor. Pulsed measurements are performed with a  $3.0\text{-}\mu\text{s}$  collector voltage pulse and a  $2.5\text{-}\mu\text{s}$  base voltage pulse, the leading edge of the latter trails that of the former by  $0.3 \mu\text{s}$ .  $I_B$ ,  $I_C$ ,  $V_{BE}$ ,  $V_{BC}$ , and  $S$ -parameters are sampled at  $1.7 \mu\text{s}$  after the leading edge of the base voltage pulse. This time delay is a compromise between measurement accuracy and self-heating.

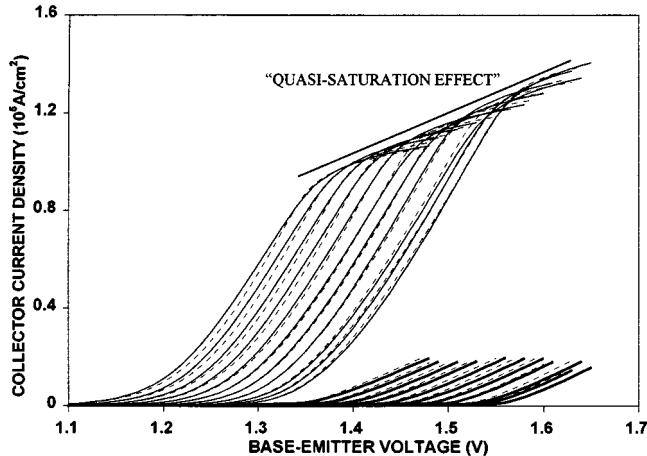


Fig. 2. Measured forward Gummel plots of (—) base and (—) collector currents versus (—) that modeled.  $V_{BC} = 0$ .  $T_C = 5^\circ\text{C}, 15^\circ\text{C}, 25^\circ\text{C}, 40^\circ\text{C}, 55^\circ\text{C}, 70^\circ\text{C}, 85^\circ\text{C}, 100^\circ\text{C}, 115^\circ\text{C}, 130^\circ\text{C}$ , and  $145^\circ\text{C}$  right to left.

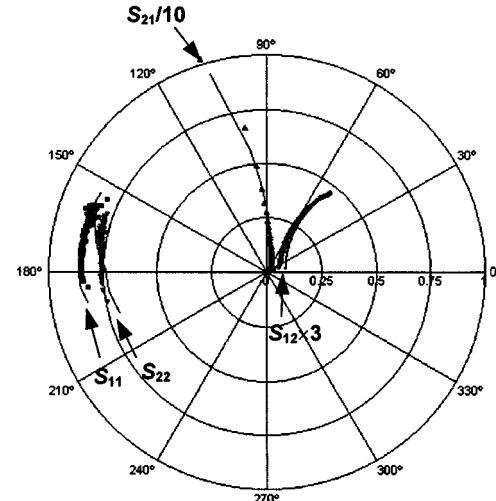


Fig. 4. (symbols) Measured versus (—) modeled  $S$ -parameters.  $V_{CE} = 1.6 \text{ V}$ ,  $J_C = 9.3 \times 10^4 \text{ A/cm}^2$ ,  $T_C = 25^\circ\text{C}$ ,  $f = 1$  to 30 GHz. Arrows indicate lower frequency limits.

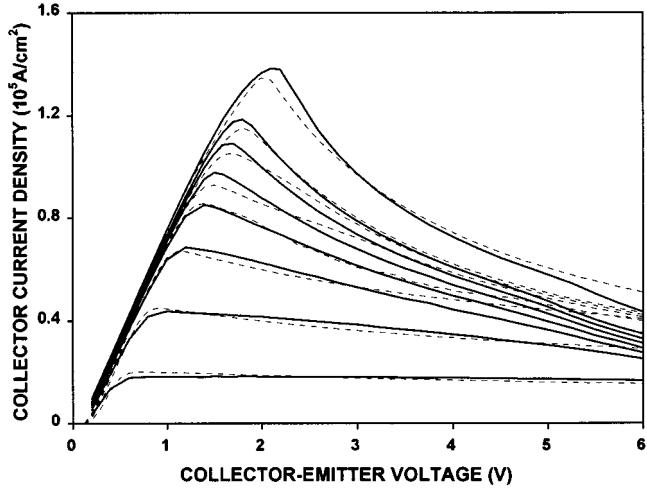


Fig. 3. (—) Measured versus (—) modeled dc collector  $I$ - $V$  characteristics.

Assuming an exponential  $T_J$  rise over time (see Nomenclature and [13]), the amount of self-heating at  $1.7 \mu\text{s}$  is reduced by approximately 80% as compared to continuous wave (CW) measurements. The pulsed measurements allow the HBTs to be characterized under very high current biases so that the Kirk and quasi-saturation effects can be better separated. Pulsed measurements also allow one to separate electrical and thermal effects. Fig. 2 shows typical forward Gummel plots. Fig. 3 shows typical collector characteristics. Fig. 4 shows typical  $S$ -parameters under a high-current and low-voltage bias.

The measured  $S$ -parameters were fitted to an equivalent circuit model of the "T" topology (Fig. 5) in a semianalytical manner [14], [15]. In particular,  $\tau_B$  and  $\tau_C$  were extracted from  $\alpha$ , after  $r_E$  was calculated from the measured dc  $I_E$  and  $C_{BEJ}$  was extracted from the so-called "cold HBT" measurement ( $V_{CE} = 0 \text{ V}$ ,  $V_{BE} = 0 \text{ V}$ ) (see [16]). The cold HBT measurement also yields  $C_{BCJ}$  and  $C_{EX}$ , after  $X_C$  is determined from the device layout. Knowing  $C_{BCJ}$ ,  $C_{BCD}$  is evaluated at each bias and temperature by fitting the intrinsic  $Y$ -parameters that

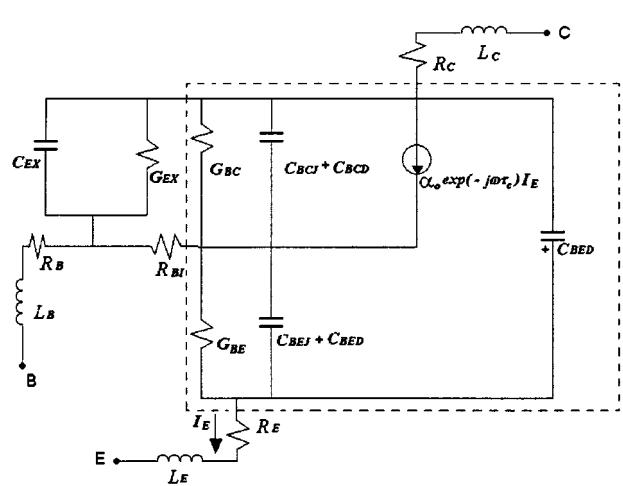


Fig. 5. Small-signal equivalent circuit model. The intrinsic HBT is encircled by a dashed line.

are obtained after deembedding the extrinsic elements from the measured  $S$ -parameters. The model parameter values for the same bias as in Fig. 4 have been included with this paper's Nomenclature.

From the small-signal equivalent-circuit models extracted at different bias points, a modified Gummel-Poon model was constructed with a new diffusion charge model (Section III). Base and collector saturation currents, ideality factors, junction capacitances, and extrinsic resistances are all made to depend on  $T_J$ . Forward and reverse saturation currents are assumed different in contrast to the standard Gummel-Poon model. Fig. 6 illustrates the large-signal model topology. Definition and typical values of the large-signal model parameters have also been included in this paper's Nomenclature.

Compared to other HBTs of comparable emitter area, the present HBTs have a relatively large  $R_C$  due to a relatively long collector finger. For the same reason, the temperature dependence of  $R_C$  is characteristic of Au instead of GaAs.

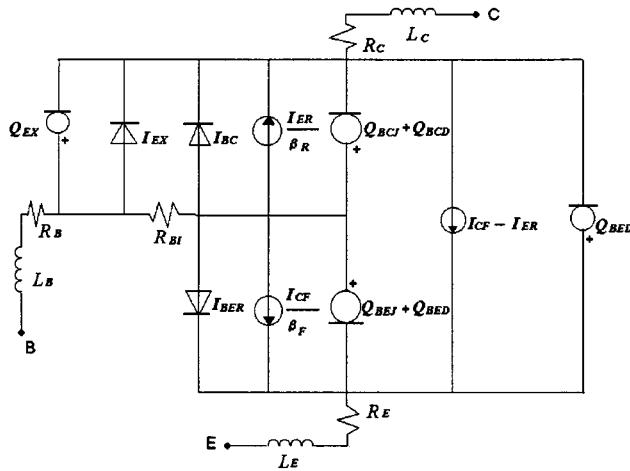


Fig. 6. Large-signal equivalent-circuit model.

The correlation between the small- and large-signal models can be found by considering the low-frequency limit of the small-signal model. From the small-signal model

$$I_C = I_E \alpha_F(\omega) = G_{BE} V_{BE} \frac{\alpha_0 e^{-j\omega\tau_C}}{1 + j\omega(\tau_B + r_{BE}C_{BEJ})} \approx \alpha_0 G_{BE} V_{BE} \left\{ 1 - j\omega(\tau_B + \tau_C + r_{BE}C_{BEJ}) \right\} \quad (1)$$

$$C_{BED} = \alpha_F \tau_B G_{BE} = \frac{\partial Q_{BED}(V_{BE}, V_{BC})}{\partial V_{BE}}. \quad (2)$$

Thus, the diffusion capacitance  $C_{BED}$  and transcapacitance  $C_{CET} = C_{BED}$  of the small-signal model correspond to the diffusion charge  $Q_{BED}$  of the large-signal model.

The large-signal model was installed in a commercially available harmonic-balance circuit simulator.<sup>1</sup> The simulated large-signal characteristics were compared with that measured. Large-signal characteristics in both frequency and time domains were measured by using an HP 71500A microwave transition analyzer. Typically, the HBT is biased with  $V_{CE} = 5$  V. The base current was derived from a voltage supply through a  $33\text{-}\Omega$  series resistor, which gave a quiescent  $J_C = 1.3 \times 10^4 \text{ A/cm}^2$ .

### III. ANALYSIS

Kirk effect occurs when  $J_C \geq J_K$  so that the field at the base-collector junction vanishes. Without the retarding field, holes spill from the base into the collector, thus extending the effective base thickness. The main impact of the Kirk effect on large-signal model parameters is in terms of a longer  $\tau_B$  due to the extended base thickness and a larger  $C_{BCD}$  due to the hole charge in the extended base. Following [1], the threshold collector current density for the onset of the Kirk effect may be approximated as

$$J_K = \left( 1 + 2\varepsilon \frac{\phi_{CB} - V_{BCI}}{qN_C W_C^2} \right) qN_C v_{SAT}. \quad (3)$$

For the present n-p-n HBTs,  $\phi_{CB} > 0$  and  $V_{BCI} < 0$ . Assuming  $V_{BCI} = 0$ ,  $J_K = 3.7 \times 10^4 \text{ A/cm}^2$  at  $T_J = 298$  K.

<sup>1</sup>Agilent Technologies Inc., Westlake, CA.

When  $T_J$  increases due to ambient change or self-heating,  $J_K$  would decrease with increasing  $T_J$  mainly through the temperature dependence of  $v_{SAT}$ . Thus, at  $T_J = 498$  K,  $J_K = 2.2 \times 10^4 \text{ A/cm}^2$ —almost one-half of the room-temperature value.

Quasi-saturation occurs when  $J_C$  approaches another level  $J_Q$  so that most of  $V_{BC}$  drops across  $R_C$ . In this case,  $\phi_{CB} \approx V_{BCI}$  and the base-collector junction is no longer reverse biased. Therefore,

$$J_Q = \frac{\phi_{CB} - V_{BC}}{R_C A_E}. \quad (4)$$

Notice that, while  $J_K$  is a threshold above which the Kirk effect becomes significant,  $J_Q$  is a practical limit so that quasi-saturation needs to be considered even when  $J_C$  is only a fraction of  $J_Q$ . In general,  $J_Q$  decreases with increasing temperature mainly through the temperature dependence of  $R_C$ . With  $V_{BC} = 0$  and  $T_J = 298$  K,  $J_Q = 3.1 \times 10^5 \text{ A/cm}^2$ , which would seem too large to be relevant. However, with  $T_J = 498$  K,  $J_Q$  is reduced to  $1.1 \times 10^5 \text{ A/cm}^2$  and becomes a real concern.

The cumulative self-heating, Kirk and quasi-saturation effects have been analyzed in detail. One-dimensional continuity equations were solved analytically for holes and electrons in the extended base under the following assumptions.

- 1) Quasi-neutrality is maintained in the extended base so that the hole concentration quickly drops from the order of  $N_B$  in the base to the order of  $N_C$  in the extended base then follows the same distribution as the electron concentration.
- 2) The electrical field is constant and low in the extended base that most of  $\phi_{CB} - V_{BCI}$  drops across the remaining collector (the collector region that has not been taken over by the extended base) and holes and electrons simply diffuse through the extended base.
- 3) The electron diffusivity is much higher than the hole diffusivity and both satisfy the Einstein relationship [17] with the low-field mobility.
- 4) Electrons drift across the remaining collector at a constant  $v_{SAT}$ .

Based on these assumptions, (A3) and (A5) for electric field and electron carrier density arise (see the Appendix for a more detailed derivation). The analytical results were found in reasonable agreement with that obtained by using a commercially available two-dimensional physical device simulator.<sup>2</sup> Fig. 7(a) depicts the Kirk effect in terms of the distribution of electrons and holes across the extended base. In this case,  $n_C$  is independent of  $V_{BCI}$  and is a function of  $J_C$  only. Fig. 7(b) depicts the distribution of electrons and holes after the quasi-saturation effect also sets in. In this case,  $n_C$  is determined by both  $J_C$  and  $V_{BCI}$ .

Under the above assumptions and according to the derivation shown in the Appendix

$$Q_{BCD} \approx I_C \frac{(\Delta W_B)^2}{4D_N} + q\Delta W_B n_C A_E \quad (5)$$

<sup>2</sup>Silvaco International, Santa Clara, CA.

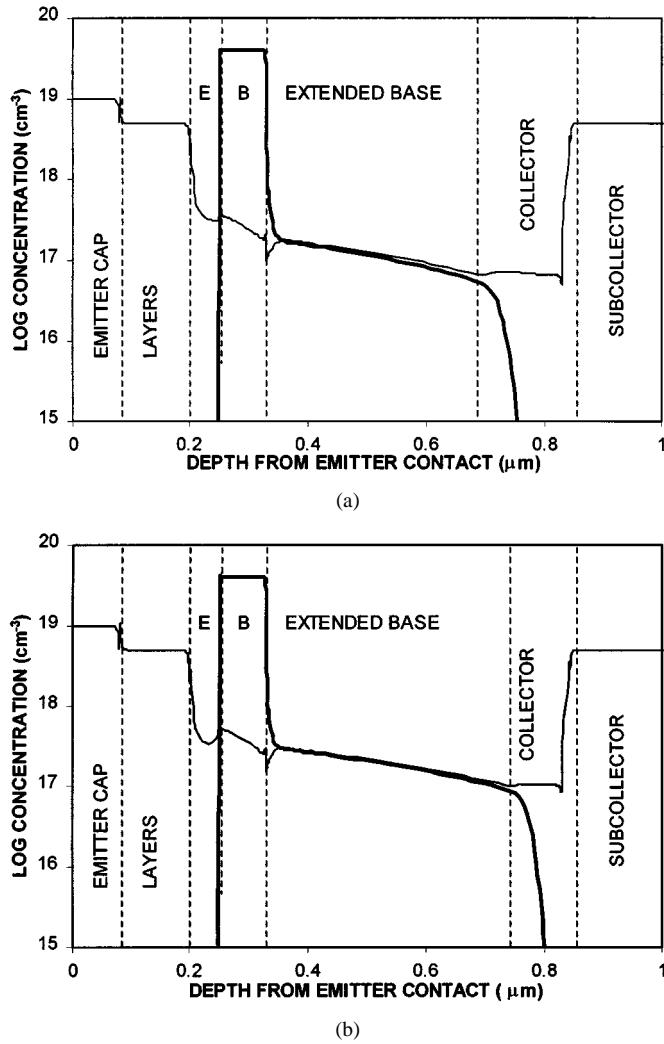


Fig. 7. Schematic illustration of (—) p and (—) n after onset of: (a) Kirk effect and (b) both Kirk and quasi-saturation effects. The self-heating effect is included in both (a) and (b). In (a),  $J_C = 0.83 \times 10^5 \text{ A/cm}^2$ ,  $V_{BCI} = 0$ ,  $\Delta W_B = 0.38 \mu\text{m}$ ,  $n_C = 7.1 \times 10^{16} \text{ cm}^{-3}$ , and  $T_J = 403 \text{ K}$ . In (b),  $J_C = 1.3 \times 10^5 \text{ A/cm}^2$ ,  $V_{BCI} = 0.5 \text{ V}$ ,  $\Delta W_B = 0.42 \mu\text{m}$ ,  $n_C = 2.3 \times 10^{17} \text{ cm}^{-3}$ , and  $T_J = 453 \text{ K}$ .  $Q_{BCD} = Q_{BCDF} + Q_{BCDR}$ .

where according to [1]

$$\Delta W_B \approx W_C - \sqrt{\frac{2\epsilon(\phi_{CB} - V_{BCI})}{\frac{J_C}{v_{SAT}} - qN_C}} \quad (6)$$

and by adding to the term due to  $J_C$  an additional Shockley term due to  $V_{BCI}$

$$n_C \approx n_0 \exp \left\{ \frac{qV_{BCI} - E_G}{kT_J} \right\} + \frac{J_C}{qv_{SAT}}. \quad (7)$$

Using the above equations,  $\tau_B$  and  $C_{BCD}$  can be evaluated by considering the partial derivatives of  $Q_{BCD}$  with respect to  $J_C$  and  $V_{BCI}$ , respectively. The first and second terms of (5) are related to the Kirk and quasi-saturation effects, respectively. The derivative of the first term with respect to  $J_C$  can be approximated by a hyper-tangent function because  $\Delta W_B$  has a sublinear dependence on  $J_C$  and is ultimately bound by  $W_C$ .

On the other hand, the derivative of the second term with respect to  $J_C$  is dominated by the exponential dependence of  $n_C$  on  $V_{BCI}$ . Therefore, substituting (6) and (7) into (5) and taking corresponding derivatives of (5) yields

$$\tau_B = \tau_{B0} + \tau_{BK} \cdot F(J_C, V_{BCI}) + \tau_{BQ} e^{\frac{qV_{BCI} - E_G}{kT_J}} \quad (8)$$

$$\frac{C_{BCD}}{A_E} = \tau_{BK} \left| \frac{\partial J'_K}{\partial V_{BCI}} \right| \left\{ F(J_C, V_{BCI}) - F(0, V_{BCI}) \right\} + \frac{\tau_{BQ} J_C}{V_T} e^{\frac{qV_{BCI} - E_G}{kT_J}} \quad (9)$$

$$F(J_C, V_{BCI}) = 1 + \tanh \left\{ \frac{J_C - J'_K}{J_0} - 1 \right\} \quad (10)$$

$$J'_K = J'_{K0} \left\{ 1 - \frac{\delta v_{SAT}}{1 \text{ cm/s}} (T_J - 298) \right\} \left( 1 + \frac{\phi_{CB} - V_{BCI}}{\phi_{CB} + V_{PT}} \right)^{M_K}. \quad (11)$$

Notice that the analytical expression of (3) has been replaced by the semiempirical expression of (11) to facilitate more accurate fitting of data.

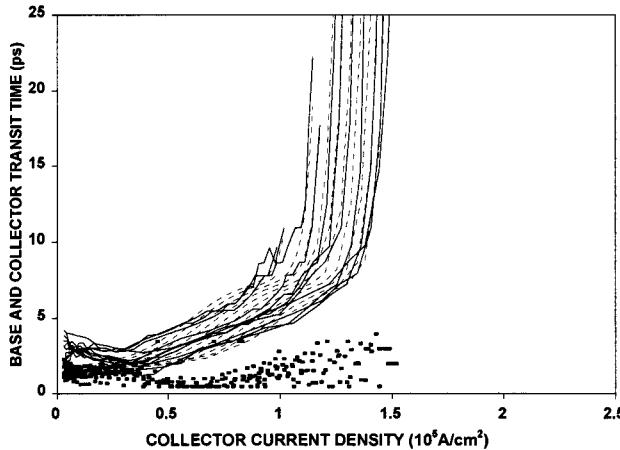
Fig. 8 shows that (8) and (9) fit extracted  $\tau_B$  and  $C_{BCI}$  reasonably well. Equations (8) and (9) were then integrated with respect to  $J_C$  and  $V_{BCI}$  to yield  $Q_{BCD}$ . Fig. 8(a) also shows that  $\tau_C$  increases approximately linearly with  $J_C$ . Therefore, a treatment similar to [18] was adapted for  $\tau_C$ , as listed at the beginning of this paper.

#### IV. DISCUSSION

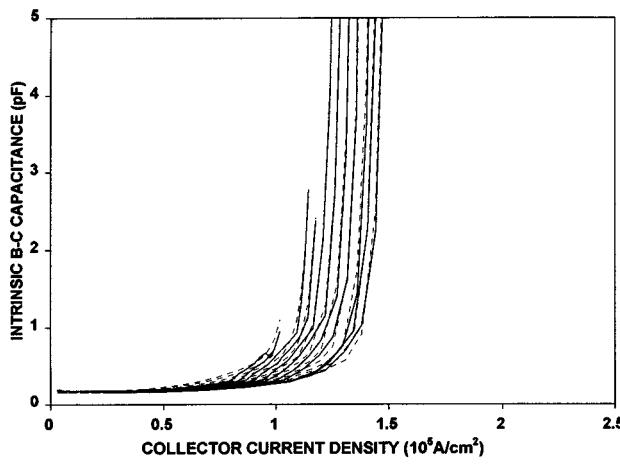
##### A. DC Results

Fig. 2 shows a good agreement between measured and modeled temperature-dependent forward Gummel plots. The quasi-saturation effect is obvious and is exacerbated by temperature. In comparison, the dc Kirk effect appears to be negligible. This is because the hole charge in the extended base is much smaller than that in the original base. The hole charge in the extended base can be approximated by  $J_C(\Delta W_B)^2/2D_N$ . With a generous estimate of  $J_C = 10^5 \text{ A/cm}^2$ ,  $\Delta W_B = 0.5 \mu\text{m}$ , and  $D_N = 25 \text{ cm}^2/\text{s}$ ,  $J_C(\Delta W_B)^2/2D_N \approx 5 \times 10^{-6} \text{ C/cm}^2$ . By contrast, the hole charge in the original base can be approximated by  $qN_B W_B = 6 \times 10^{-5} \text{ C/cm}^2$ .

By properly accounting for the temperature dependence of thermal resistance, saturation currents, ideality factors, and terminal resistances, Fig. 3 shows that the modeled and measured collector characteristics are also in good agreement up to  $3 \times 10^5 \text{ W/cm}^2$  dissipated power under which severe self-heating takes place. Notice that, although power dissipation at the quiescent point is approximately  $1 \times 10^5 \text{ W/cm}^2$ , under a large RF drive, dissipated power can increase to  $3 \times 10^5 \text{ W/cm}^2$  due to the self-biasing effect. In this case, both high-temperature and high-current effects need to be modeled accurately.



(a)



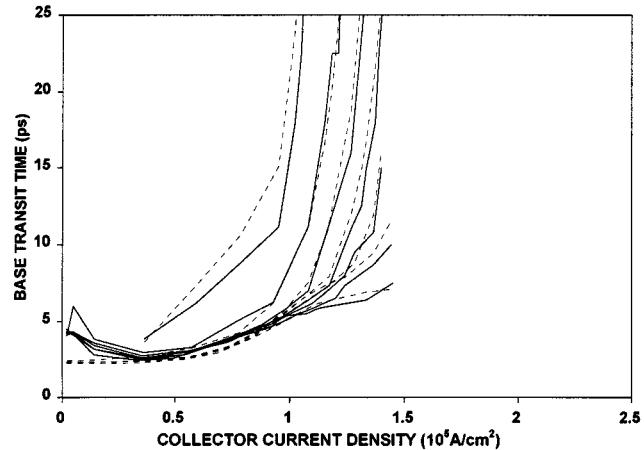
(b)

Fig. 8. (a) (—) Extracted versus (—) modeled base transit time as well as (■) extracted collector transit time. (b) (—) Extracted versus (—) modeled intrinsic base-collector capacitance.  $V_{BCI} = -1$  V.  $T_C = 5$  °C, 15 °C, 25 °C, 40 °C, 55 °C, ..., 145 °C right to left.

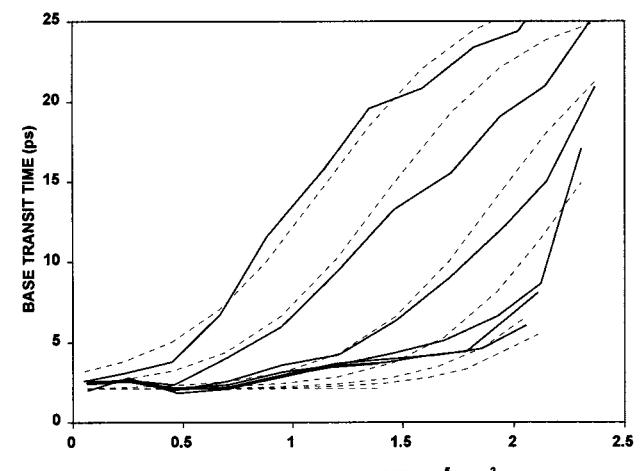
### B. Small-Signal Results

Depending on the current density, different interplays between the self-heating, Kirk, and quasi-saturation effects are manifested. For example, for  $J_C$  between approximately 0.4 and  $1.2 \times 10^5$  A/cm<sup>2</sup>, the Kirk effect dominates so that  $\tau_B$  and  $C_{BCI}$  increase approximately linearly with  $J_C$ . However, the temperature and quasi-saturation effects cannot be entirely ignored even within this current range. The effect of temperature on  $J_K$  was discussed in Section III and is reflected in Fig. 8. To separate out the effect of quasi-saturation, Fig. 9(a) replots  $\tau_B$  at  $T_C = 25$  °C under different  $V_{BCI}$  values. It can be seen that so long as  $V_{BCI} < 0.65$ ,  $\tau_B$  increases approximately linearly with  $J_C$  under CW conditions.

For  $J_C \geq 1.2 \times 10^5$  A/cm<sup>2</sup>, the quasi-saturation effect dominates under CW conditions so that  $\tau_B$  and  $C_{BCI}$  increase exponentially with  $J_C$ , as predicted by (8), given the linear relationship between  $J_C$  and  $V_{BCI}$ . On the other hand, under pulsed test conditions, self-heating, hence, quasi-saturation, is significantly reduced, and the region where the Kirk effect dominates can be further extended. Fig. 9(b) plots  $\tau_B$  extracted from pulsed S-parameters under different  $V_{BCI}$  values. It can be seen that



(a)



(b)

Fig. 9. (—) Extracted base transit time at different intrinsic base-collector voltages under: (a) CW and (b) pulsed bias conditions versus that (—) fitted.  $T_C = 25$  °C. (a)  $V_{BCI} = 0.65, 0.7, 0.75, 0.8, 0.85, 0.9$ , and 1.0 V and (b)  $-0.5, -0.25, 0, 0.25, 0.55, 0.75$ , and 1.0 V right to left.

as long as  $V_{BCI} < 0$ ,  $\tau_B$  would increase approximately linearly even for  $J_C \approx 2 \times 10^5$  A/cm<sup>2</sup>.

### C. Large-Signal Results

Fig. 10 shows the power performance at 2 GHz with the input and output matched for maximum PAE. Up to seven harmonics were included in both measurement and simulation. In each case, the measured performance was compared with that modeled with the cumulative self-heating, Kirk, and quasi-saturation effects, or with just the self-heating effect.

In general, both models are in good agreement with the measured fundamental output power and gain. However, without the relatively abrupt quasi-saturation effect, the model with just self-heating underestimates even harmonics, but overestimates odd harmonics. In addition, the model with just self-heating underestimates the dc current level hence underestimates the junction temperature, but overestimates the efficiency. In comparison, the model with the cumulative self-heating, Kirk, and quasi-saturation effects are in agreement with all aspects of power performance, even under deep gain compression.

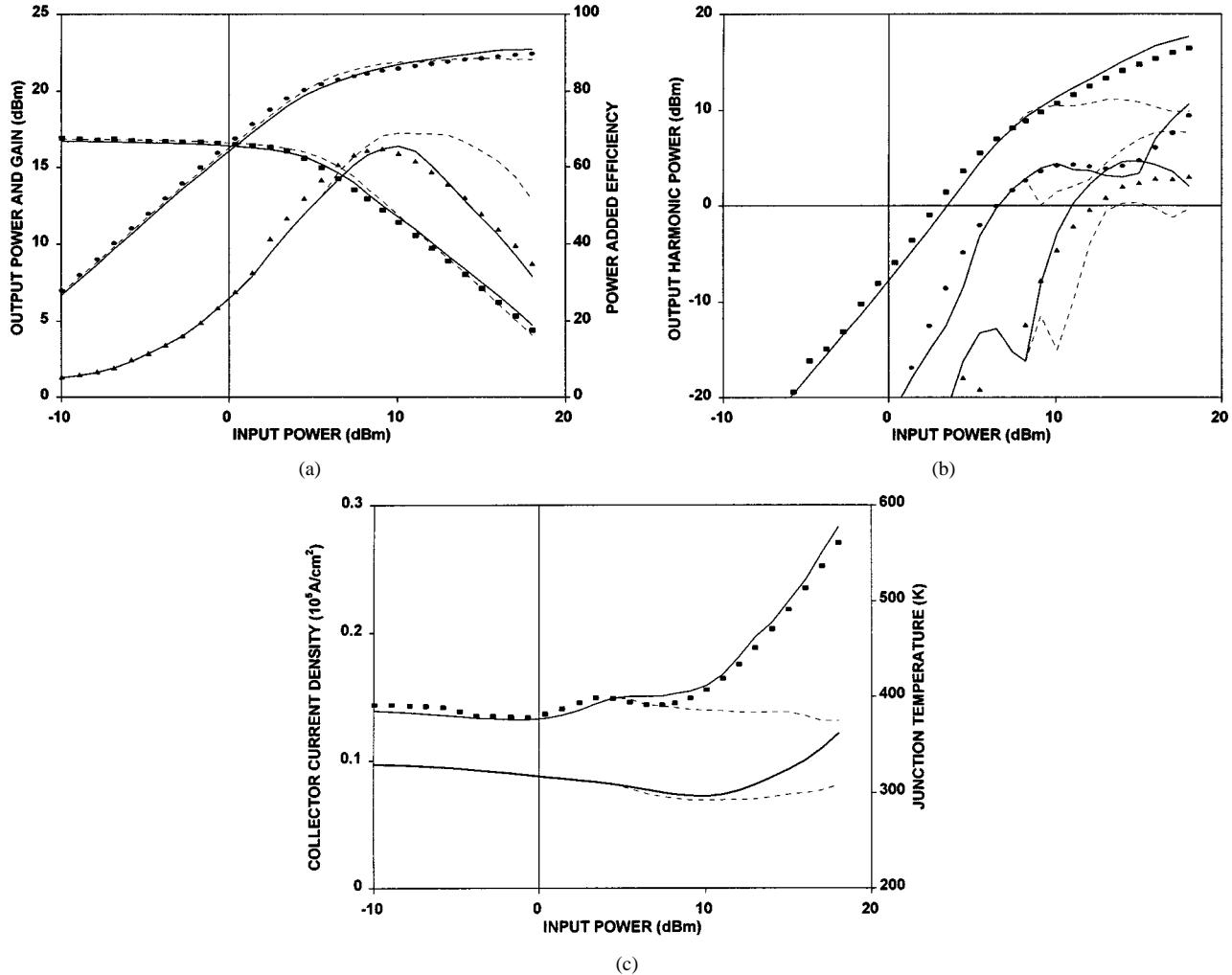


Fig. 10. (a) (●) Fundamental output power, (■) gain, and (▲) PAE. (b) (■) second, (●) third, and (▲) fourth harmonic output power. (c) (■) collector current density and (—) junction temperature measured at 2 GHz on an HBT that is matched for maximum PAE. (—) Modeled with both high-current and high-temperature effects. (—) Modeled with the high-temperature effect only. Under quiescent conditions,  $V_{CE} = 5$  V,  $J_B = 1.2 \times 10^2$  A/cm<sup>2</sup>.

The deficiency of the self-heating only model is probably caused by neglecting the displacement current associated with  $C_{BCD}$ , thereby underestimating harmonic powers and currents associated with the displacement current when the HBT is driven into compression. This is consistent with the dynamic load lines measured under the same conditions, as shown in Fig. 1.

Measured and modeled power performance under other bias, match and drive conditions are in similar agreement. The present large-signal model is based on smooth functions such as hyper tangent and exponential functions, and is specifically designed for robust harmonic-balance simulation of power HBTs. Typically, convergence is reached within the same time frame as that of the standard (without any modification for self-heating or quasi-saturation effect) Gummel-Poon model.

According to (8), increase in  $\tau_B$  by the Kirk effect alone (before quasi-saturation) is rather moderate. For example, at  $T_C = 25^\circ\text{C}$ ,  $\tau_B$  increases from 2 to 5 ps when  $J_C$  increases from 0 to  $10^5$  A/cm<sup>2</sup>. Such an increase in  $\tau_B$  was found to have relatively mild impact on large-signal performance at 2 GHz, but may be more critical at higher frequencies.

The simulation of Fig. 10 has been repeated with or without the Kirk effect ( $\tau_{BK} = 12$  ps or 0), but always with self-heating and quasi-saturation effects. It was found that, under light compression, the Kirk effect reduced power gain by approximately 0.5 dB and PAE by approximately 3%. The Kirk effect also reduced clipping in the time-domain waveforms, hence, increased even harmonics. For example, the second harmonic was reduced by approximately 2 dB under the same input power. This is because without the Kirk effect, the HBT has a higher gain and compresses at a lower input power level.

We also performed the simulations at  $V_{CE} = 3$  V and found that when output match was compromised for peak PAE and  $P_{OUT}$ , the Kirk effect was still shunt by the quasi-saturation under heavy compression. Similar simulations were repeated under the same bias conditions, but with the input and output matched for the maximum output power at 10 GHz. In this case, reduction of power gain of  $\sim 2.5$  dB and PAE of  $\sim 10\%$  was found due to the Kirk effect under slight compression. This confirms that the Kirk effect will have a more severe impact when the frequency approaches a significant fraction of the cutoff frequency of the HBT.

TABLE I  
EFFECT OF Emitter GEOMETRY

Emitter Width (μm)	Emitter Length (μm)	Collector Resistance $R_{C0}$ (Ω)	Thermal Resistance $\Theta_0$ (°C/W)
3	100	0.9	200
4	75	1.4	280
6	50	1.8	350

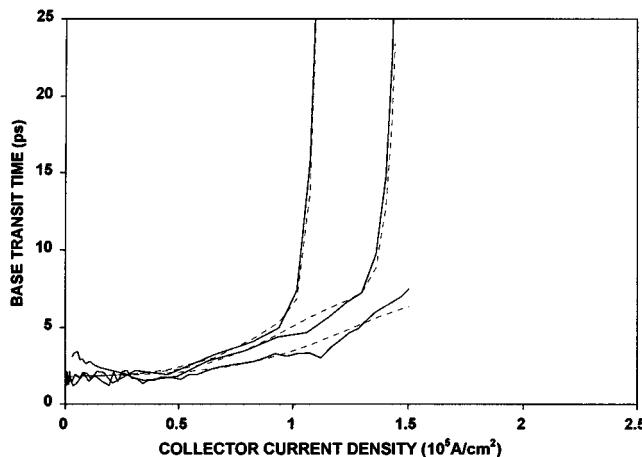


Fig. 11. (—) Extracted versus (—) modeled base transit time for an emitter of  $3 \times 100$ ,  $4 \times 75$ , and  $6 \times 50 \mu\text{m}^2$  right to left.  $V_{BC} = -1 \text{ V}$ .  $T_C = 25^\circ\text{C}$ .

#### D. Effect of Emitter Geometry

Since the emitter geometry can potentially affect other high-current effects such as the emitter crowding effect [1], two additional types of HBTs with a narrower or wider emitter, but the same emitter area were characterized. The results were then compared with the first type of HBTs. As shown in Table I, the main effect of emitter geometry was for thermal and collector resistances to increase with emitter width, as one would expect by inspecting the layout of the devices. Once the proper values of  $\Theta$  and  $R_C$  are used in the model, the model predicts the correct characteristics such as  $\tau_B$  for all three types of HBTs (Fig. 11). Therefore, the emitter crowding effect appears to be negligible in the present HBTs, probably due to their relatively high gain.

#### E. Comparison With Literature

The Kirk effect has been extensively studied in Si bipolar junction transistors (BJTs) [19]. Base push-out was deemed as a possible cause for the observed bending in dc  $I$ - $V$  characteristics at high currents. Recently, a physics-based model was reported for a high-speed Si BJT in which  $\tau_B$  was considered as a function of  $J_C$ ,  $V_{CE}$ , and  $T_J$  [20]. At high  $V_{CE}$ , the model predicted a gradual increase of  $\tau_B$  after the onset of the Kirk effect, which was followed by saturation of  $\tau_B$  for  $J_C \geq 3.5 \times 10^5 \text{ A/cm}^2$ . Such a behavior is very similar to that predicted by the hyper tangent term of (8). At low  $V_{CE}$ , [20] reported a steep increase in  $\tau_B$ , but did not dwell upon the reason. The similarity between their results and the present observation suggests self-heating, as well as quasi-saturation effects are responsible for such a steep increase of  $\tau_B$ .

By comparison, none of the large-signal HBT models known to us considers the base-collector diffusion charge under quasi-

saturation. The quasi-saturation effect has not been considered in HBTs perhaps because HBTs are not expected to sustain as high a static current density as the BJTs due to the more severe self-heating effect in HBTs. However, this paper shows that high current density can be reached momentarily under large RF swings, whereas the more severe self-heating effect can bring about the quasi-saturation effect at a lower current density.

Recently, an empirical model was reported for the Kirk effect in HBTs in which  $\tau_B$  was modeled as an exponential function of  $J_C$  [9]. The studies in this work indicate that more accurate modeling of  $\tau_B$  occurs by separating contributions from the Kirk effect and the quasi-saturation effect. As explained in Sections III and IV-B, the contribution to  $\tau_B$  from the Kirk effect is gradual and eventually saturates with increasing  $J_C$ . At very high current density, an exponential dependence of  $\tau_B$  on  $J_C$  is observed, but it is due to the quasi-saturation effect, not the Kirk effect. Although the empirical model of [9] apparently works in the medium current range, when extended to higher currents, it may erroneously regard quasi-saturation as an extension of Kirk effect.

#### V. CONCLUSION

Accurate prediction of HBT large-signal characteristics under high currents is important because, as the trend for lower supply voltage continues, higher peak currents are required for RF power generation. It was found that, in addition to cause self heating, high currents can cause Kirk and quasi-saturation effects that are critical for large-signal characteristics of InGaP/GaAs HBTs, especially when these HBTs are driven into heavy compression to maximize their power output or efficiency. Other high-current effects, such as the emitter crowding effect, appear not as important for the present devices.

#### APPENDIX DERIVATION OF (5)

The total electron charge in the extended base can be obtained by integrating the electron distribution there after the onset of the Kirk effect. Electron distribution can be obtained by solving the continuity equation

$$D_N \frac{\partial n(x)}{\partial x} + \mu_N E(x)n(x) = \frac{-J_C}{q} \quad (A1)$$

assuming the collector current is mostly carried by electrons due to their higher diffusivity than that of holes. On the other hand, the electrical field can be found by solving the continuity equation for holes

$$-D_P \frac{\partial p(x)}{\partial x} + \mu_P E(x)p(x) \approx 0. \quad (A2)$$

Thus,

$$E(x) \approx \frac{D_P}{\mu_P} \frac{1}{p(x)} \frac{\partial p(x)}{\partial x} = \frac{D_N}{\mu_N} \frac{1}{n(x)} \frac{\partial n(x)}{\partial x} \quad (A3)$$

according to the quasi-neutral assumption  $n(x) \approx p(x)$  (neglecting  $N_C$ ) and the Einstein relationship. Substituting (A3) into (A1)

$$\frac{\partial n(x)}{\partial x} = \frac{-J_C}{2qD_N}. \quad (\text{A4})$$

Integrating (A4) with respect to  $x$  with the boundary condition  $n(\Delta W_B) = n_C$ , we have

$$n(x) = n_C + \frac{J_C}{2qD_N} \cdot (\Delta W_B - x). \quad (\text{A5})$$

Finally, (5) can be obtained by integrating (A5) once more with respect to  $x$  and multiplying the result with  $qA_E$ .

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